

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PATENT
YOR919980056US 1
IBM-304

In re Application of

Marie Angelopoulos

Serial Number

09/256,034

Filing Date

February 23, 1999

Examiner

John S. V. Chu

Group Art Unit

1752



For

MULTILAYERED RESIST SYSTEMS
USING TUNED POLYMER FILMS AS
UNDERLAYERS AND METHODS OF
FABRICATION THEREOF

The Honorable Commissioner of Patents
Post Office Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated February 22, 2006, please amend the above-identified application as follows:

IN THE CLAIMS Cancel Claims 6, 9 – 17 and 19.

REMARKS

In response to the prior Official Action in this case, Applicants amended Claim 1 to include "photosensitive elements" for the resist material used in the method, and specified therein the thickness of the layers and the units thereof. 35 U.S.C. § 112, second paragraph, as being incomplete.

Applicants have cancelled Claims 6, 9 – 17 and 19.

Claim 3 has been previously cancelled. The Examiner has rejected Claim 6 which was cancelled in